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## **A Century of Dielectric Science and Technology -**

The International Technology in Semiconductor Device Manufacturing symposium, K. Wolke, in Cleaning Technology in Semiconductor Device

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**Patent US7906414 - Single-shot semiconductor -**

Method of manufacturing semiconductor device having Layers,"  
1989 Proceedings, Sixth International IEEE VLSI State  
Science and Technology,

**Related to Standard - ASTM International -**

Fretting Fatigue: Advances in Basic Understanding and  
Applications: Sixth Volume: STP1054: Science and Technology  
of Glazing Systems: Sixth International

**T. Hattori (Editor of Cleaning Technology in -**

T. Hattori is the author of Cleaning and Surface  
Conditioning Technology in Semiconductor Device  
Manufacturing; Proceedings (0.0 avg rating, 0 ratings, 0

**Patent US6984571 - Three dimensional device -**

The first, second and third workpieces may each be a  
semiconductor device having a thin material formed on one  
surface, preferably in wafer form.

**MEMS Wet-Etch Processes and Procedures - Springer -**

MEMS Wet-Etch Processes and Procedures on Cleaning  
Technology in Semiconductor Device 6th International  
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**UNIVERSITY OF ILLINOIS AT CHICAGO -**

Computer Science, Proceedings of the Third International Conference on Web Search and Virtual Journal of Nanoscale Science and Technology, 2009

**Leading Edge Semiconductor Cleaning Technologies -**

Leading Edge Semiconductor Cleaning Technologies Leading Edge Semiconductor Wafer Surface Cleaning Technologies that Support the Next Generation of Semiconductor Devices

**yjs.suda.edu.cn -**

2005 International Semiconductor Device Sixth IEEE International Symposium on of Environmental Science and Technology. Proceedings

**Patent US7718517 - Single-shot semiconductor -**

A thin film semiconductor workpiece is irradiated with a laser beam to melt and recrystallize target areas of the surface exposed to the laser beam.

**ECS Meeting (9 International Symposium on Cleaning -**

208th ECS Meeting, Abstract #773, copyright ECS Abstract Submitted to 208 th ECS Meeting (9 International Symposium on Cleaning Technology in Semiconductor Device

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Cleaning Technology in Semiconductor Device Manufacturing: Proceedings to the Seventh International [J. Ruzyllo, Jerzy Ruzyo, International Symposium on Cleaning Tech

**Particle Measuring Systems Joins - -**

Particle Measuring Systems Joins SEMATECH To Advance Surface Conditioning And Wafer Cleaning Technology For Semiconductor Device Manufacturing

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(US), Atmel Cleaning by solvents